

TEMIC

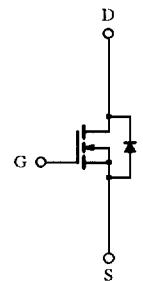
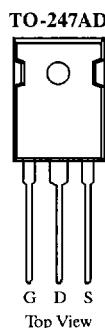
Siliconix

SMW60N10

N-Channel Enhancement-Mode Transistor

Product Summary

$V_{(BR)DSS}$ (V)	$r_{DS(on)}$ (Ω)	I_D (A)
100	0.025	60



Absolute Maximum Ratings ($T_C = 25^\circ\text{C}$ Unless Otherwise Noted)

Parameter	Symbol	Limit	Unit
Gate-Source Voltage	V_{GS}	± 20	V
Continuous Drain Current	I_D	60	A
$T_C = 100^\circ\text{C}$	I_D	37	
Pulsed Drain Current	I_{DM}	240	
Avalanche Current	I_{AR}	60	
Avalanche Energy	E_A	540	mJ
Repetitive Avalanche Energy ^a	E_{AR}	36	
Power Dissipation	P_D	180	W
$T_C = 100^\circ\text{C}$	P_D	70	
Operating Junction and Storage Temperature Range	T_J, T_{stg}	-55 to 150	
Lead Temperature ($\frac{1}{16}$ " from case for 10 sec.)	T_L	300	°C

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Thermal Resistance Ratings

Parameter	Symbol	Typical	Maximum	Unit
Junction-to-Ambient	R_{thJA}		40	°C/W
Junction-to-Case	R_{thJC}		0.7	
Case-to-Sink	R_{thCS}	0.35		

Notes:

a. Duty cycle $\leq 1\%$

Specifications ($T_J = 25^\circ\text{C}$ Unless Otherwise Noted)

Parameter	Symbol	Test Condition	Min	Typ ^a	Max	Unit
Static						
Drain-Source Breakdown Voltage	$V_{(\text{BR})\text{DSS}}$	$V_{GS} = 0 \text{ V}, I_D = 250 \mu\text{A}$	100			V
Gate Threshold Voltage	$V_{GS(\text{th})}$	$V_{DS} = V_{GS}, I_D = 250 \mu\text{A}$	2.0		4.0	
Gate-Body Leakage	I_{GSS}	$V_{DS} = 0 \text{ V}, V_{GS} = \pm 20 \text{ V}$			± 100	nA
Zero Gate Voltage Drain Current	I_{DSS}	$V_{DS} = 80 \text{ V}, V_{GS} = 0 \text{ V}$			25	μA
		$V_{DS} = 80 \text{ V}, V_{GS} = 0 \text{ V}, T_J = 125^\circ\text{C}$			250	
On-State Drain Current ^b	$I_{D(\text{on})}$	$V_{DS} = 5 \text{ V}, V_{GS} = 10 \text{ V}$	60			A
Drain-Source On-State Resistance ^b	$r_{DS(\text{on})}$	$V_{GS} = 10 \text{ V}, I_D = 37 \text{ A}$		0.020	0.025	Ω
		$V_{GS} = 10 \text{ V}, I_D = 37 \text{ A}, T_J = 125^\circ\text{C}$		0.034	0.045	
Forward Transconductance ^b	g_{fs}	$V_{DS} = 10 \text{ V}, I_D = 37 \text{ A}$	20			S
Dynamic						
Input Capacitance	C_{iss}	$V_{GS} = 0 \text{ V}, V_{DS} = 25 \text{ V}, f = 1 \text{ MHz}$		4100		pF
Output Capacitance	C_{oss}			1200		
Reverse Transfer Capacitance	C_{rss}			310		
Total Gate Charge ^c	Q_g	$V_{DS} = 50 \text{ V}, V_{GS} = 10 \text{ V}, I_D = 60 \text{ A}$		110	140	nC
Gate-Source Charge ^c	Q_{gs}			30	40	
Gate-Drain Charge ^c	Q_{gd}			52	80	
Turn-On Delay Time ^c	$t_{d(on)}$	$V_{DD} = 50 \text{ V}, R_L = 0.83 \Omega$ $I_D \approx 60 \text{ A}, V_{GEN} = 10 \text{ V}, R_G = 2.5 \Omega$		20	40	ns
Rise Time ^c	t_r			130	180	
Turn-Off Delay Time ^c	$t_{d(off)}$			40	80	
Fall Time ^c	t_f			20	40	
Source-Drain Diode Ratings and Characteristics ($T_C = 25^\circ\text{C}$)						
Continuous Current	I_S				60	A
Pulsed Current	I_{SM}				240	
Forward Voltage ^b	V_{SD}	$I_F = 60 \text{ A}, V_{GS} = 0 \text{ V}$			2.5	V
Reverse Recovery Time	t_{rr}	$I_F = 60 \text{ A}, dI_F/dt = 100 \text{ A}/\mu\text{s}$		125		ns
Reverse Recovery Charge	Q_{rr}			0.3		μC

Notes:

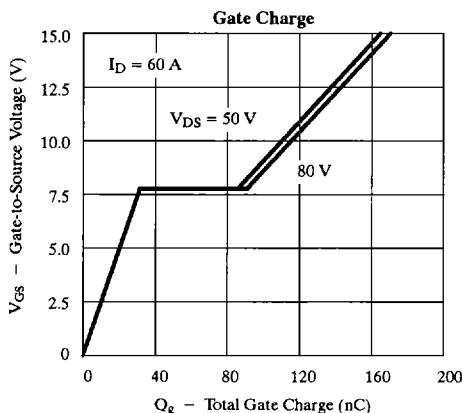
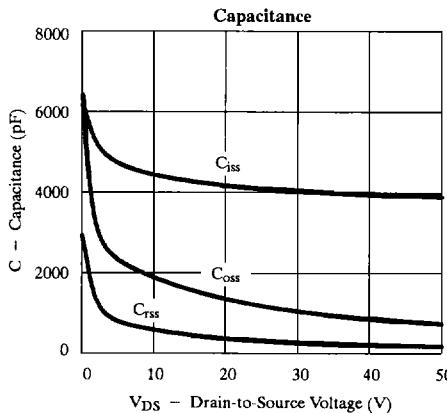
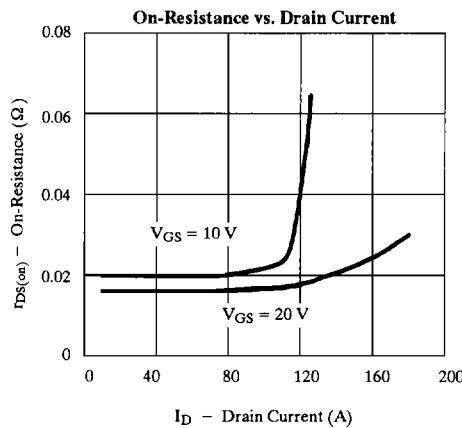
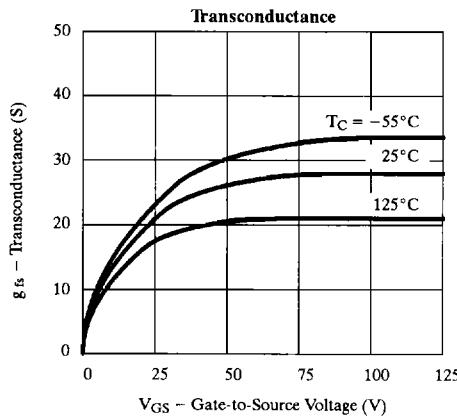
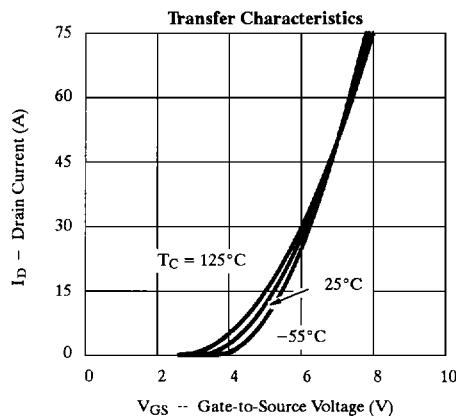
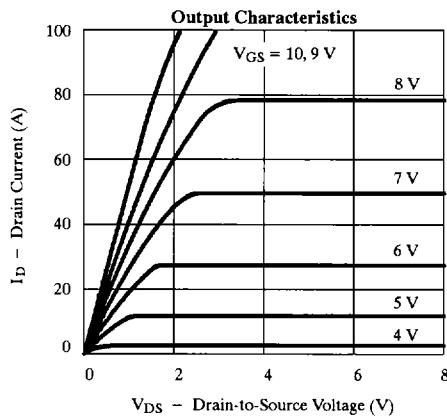
- a. For design aid only; not subject to production testing.
- b. Pulse test; pulse width $\leq 300 \mu\text{s}$, duty cycle $\leq 2\%$.
- c. Independent of operating temperature.

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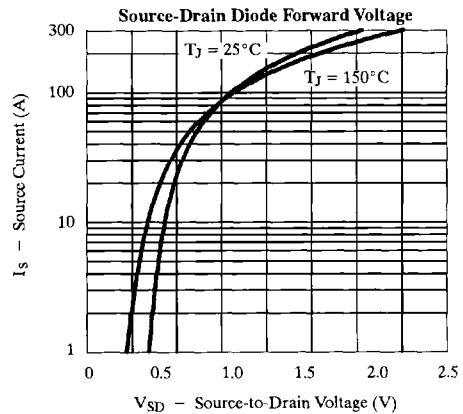
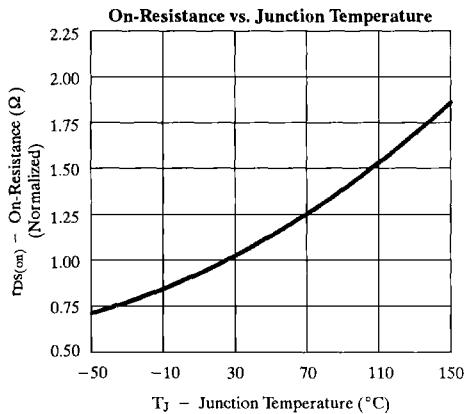
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Typical Characteristics (25°C Unless Otherwise Noted)



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